## AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

Claims 1-53 (Canceled)

- 54. (Previously presented) A solar cell comprising:
  - a germanium substrate;
- a layer of material selected from the group consisting of InP and InGaP disposed directly on the germanium substrate; and
  - a diffused photoactive germanium junction in the substrate.
- 55. (Previously presented) A solar cell as defined in claim 54, wherein the layer of material is InGaP.
- 56. (Previously presented) A solar cell as defined in claim 54, further comprising a top solar subcell formed from InGaP, a middle solar subcell formed from GaAs, and a lower solar subcell formed in the germanium substrate.
- 57. (Canceled)
- 58. (Previously presented) A solar cell as defined in claim 54, wherein the diffused junction is formed by the diffusion of arsenic into the germanium substrate.
- 69. (Previously presented) A solar cell as defined in claim 54, wherein the layer of material has a lattice parameter substantially equal to the lattice parameter of the germanium substrate.

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- 60. (Previously presented) A solar cell as defined in claim 54, wherein the layer has a thickness equal to 350 Angstroms or less.
- 61. (Previously presented) A solar cell defined in claim 54, wherein the cell is capable of photoactively converting radiation ranging from approximately ultraviolet (UV) radiation to radiation having a wavelength of approximately 1800 nm.
- 62. (Previously presented) A solar cell defined in claim 58, wherein the junction in the germanium substrate layer is located between 0.3  $\mu$ m and 0.7  $\mu$ m from the top surface of the germanium substrate.
- 63. (Previously presented) A solar cell as defined in claim 54, wherein the diffused germanium substrate forms a first cell layer and has a dopant diffusion profile that optimizes the current and voltage generated therefrom.
- 64. (Previously presented) A solar cell as defined in claim 54, wherein the cell has 1 sun AM0 efficiencies in excess of 26%.
- 65. (Currently amended) A solar cell comprising:
  - a germanium substrate;
  - a solar subcell layer overlying said substrate and composed of GaAs; and
- a barrier layer overlying said substrate and underneath said solar subcell\_layer and functioning to inhibit the diffusion of arsenic from the the solar subcell layer into the germanium substrate.

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- 66. (Previously presented) A solar cell as defined in claim 65, further comprising a solar subcell formed in the germanium substrate.
- 67. (Previously presented) A solar cell as defined in claim 66, wherein the subcell formed in the germanium substrate is formed from an n-type germanium layer overlying a p-type germanium substrate.
- 68. (Previously presented) A solar cell as defined in claim 67, wherein the n-type germanium layer is formed by diffusion of arsenic into the germanium substrate.
- 69. (Previously presented) A solar cell a defined in claim 67, wherein the n-type germanium layer is formed by diffusion of phosphorous into the germanium substrate.
- 70. (Previously presented) A solar cell as defined in claim 67, wherein the n-type germanium layer is formed by diffusion of both arsenic and phosphorous into the germanium substrate.
- 71. (Previously presented) A solar cell as defined in claim 65, wherein the barrier layer is composed of InGaP, InP, or GaP.
- 72. (Currently amended) A solar cell as defined in claim 65, wherein the barrier layer has a thickness of approximately 350 of between 201 and 350 Angstroms or less.
- 73. (Previously presented) A solar cell as defined in claim 65, further comprising a two step diffusion profile in the germanium substrate with two different dopants.
- 74. (Previously presented) A solar cell comprising:

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a first cell including a germanium (Ge) substrate having a diffusion region doped with n-type dopants including phosphorus and arsenic, wherein the upper portion of such diffusion region has a higher concentration of phosphorus (P) atoms than arsenic (As) atoms, and a second cell including a layer of either gallium arsenide (GaAs) or indium gallium

arsenide (InGaAs) disposed over the substrate.

- 75. (Previously presented) A solar cell as recited in claim 74, further comprising a nucleation layer deposited over said substrate that has a lattice parameter substantially equal to the lattice parameter of the germanium substrate.
- 76. (Previously presented) A solar cell as recited in claim 75, wherein the nucleation layer is a compound of InGaP.
- 77. (Previously presented) A solar cell as recited in claim 75, wherein the nucleation layer has a thickness equal to 350 angstroms or less.
- 78. (Previously presented) A solar cell defined in claim 74, wherein the solar cell is capable of photoactively converting radiation from approximately ultraviolet (UV) radiation to radiation having a wavelength of approximately 1800 nm.
- 79. (Previously presented) A solar cell defined in claim 74, wherein a junction in the germanium substrate is located between 0.3  $\mu$ m and 0.7  $\mu$ m from the top surface of the germanium substrate.

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- 80. (Previously presented) A solar cell as defined in claim 74, wherein diffused phosphorus and arsenic in the germanium substrate has a diffusion profile that optimizes the current and voltage generated in the first cell.
- 81. (Previously presented) A solar cell as defined in claim 75, wherein the solar cell has 1 sun AM0 efficiencies in excess of 26%.
- 82. (Previously presented) A solar cell as defined in claim 74, further comprising a third cell disposed over the second cell layer.

Claims 83-104 (Canceled)

105. (Previously presented) A triple-junction solar cell comprising:

a dual-junction structure comprising a first junction and a second junction;

a third junction having a p-type substrate, wherein the third junction is doped with

arsenic (As) and phosphorus (P), wherein the p-type substrate includes first and second diffusion sublayers, wherein P atoms have higher concentration compared to As atoms in the first diffusion sublayer and As atoms have a higher concentration compared to P atoms in the second diffusion sublayer; and

a nucleation layer disposed between the dual-junction structure and the third junction and comprising a material that shares a substantially similar lattice parameter with the p-type substrate of the third junction, wherein the nucleation layer serves to control the diffusion of arsenic atoms into the substrate.

106. (Previously presented) The triple-junction solar cell as recited in Claim 105

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wherein the p-type substrate of the third junction is germanium (Ge) and the nucleation layer comprises indium gallium phosphide (InGaP).

- 107. (Previously presented) The triple-junction solar cell as recited in Claim 105 wherein the nucleation layer has a thickness substantially equal to 350 Å or less.
- 108. (Previously presented) The triple-junction solar cell as recited in Claim 105 wherein the junction depth of the third junction is substantially between 0.3  $\mu$ m and 0.7  $\mu$ m.
- 109. (Previously presented) The triple-junction solar cell as recited in Claim 105 wherein the third junction comprises a two-step diffusion profile capable of optimizing current and voltage generated from the third junction.
- 110. (Previously presented) The triple-junction solar cell as recited in Claim 105 having 1 sun AM0 efficiencies in excess of 26%.
- 111. (Previously presented) The triple-junction solar cell as recited in Claim 105 capable of absorbing radiation ranging from approximately ultraviolet (UV) radiation to radiation having a wavelength of approximately 1800 nm.

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## 112-114. (Cancelled)

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115. (Previously presented) A multi-junction solar cell comprising:

a p-type germanium (Ge) substrate having a first surface, wherein the p-type Ge substrate further includes a diffusion portion having a first diffusion region situated adjacent to the first surface of the p-type Ge substrate and a second diffusion region, which includes a part of the first diffusion region, wherein the second diffusion region diffuses deeper into the Ge substrate than the first diffusion region;

a phosphorus (P) containing nucleation layer disposed over the first surface of the ptype Ge substrate, wherein the P containing nucleation layer provides n-type P atoms to the first diffusion region; and

an arsenic (As) containing buffer layer disposed over the P containing nucleation layer, wherein the As containing buffer layer provides n-type As atoms to the second diffusion region in response to the thickness of the P containing nucleation layer, wherein the second diffusion region has a higher concentration of As atoms than P atoms.

- 116. (Previously presented) The multi-junction solar cell of claim 115, further comprising a second surface situated at the bottom of the multi-junction solar cell.
- 117. (Previously presented) The multi-junction solar cell of claim 115, wherein the first diffusion region has a higher concentration of P atoms than As atoms.
- 118. (Previously presented) A multi-junction solar cell comprising:

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a germanium (Ge) substrate having a first diffusion region and a second diffusion

region, wherein the second diffusion region diffuses deeper into the Ge substrate than the first

diffusion region;

a phosphide nucleation layer disposed over the first surface of the substrate, wherein the

phosphide nucleation layer provides diffusion dopants of phosphorus (P) atoms to the first

diffusion region; and

an arsenide layer disposed over the phosphide nucleation layer, wherein the arsenide

layer provides diffusion dopants of arsenic (As) atoms into the second diffusion region in

response to the thickness of the phosphide nucleation layer, wherein the first diffusion region

has a higher concentration of P atoms than As atoms.

119. (Previously presented) The multi-junction solar cell of claim 118, further

comprising a second surface situated at the bottom of the multi-junction solar cell.

120. (Previously presented) The multi-junction solar cell of claim 118, wherein the

second diffusion region has a higher concentration of As atoms than P atoms.

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